# ASP-DAC: 8A-1 <br> A New Graph-Theoretic, MultiObjective Layout Decomposition Framework for Double Patterning Lithography 

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## Outline

- Motivation
-Bi-Partitioning Based Decomposition
- Timing Driven Decomposition
- Experimental Results
- Future Works


## Layout Decomposition

## LELE DPL Process


[Initial Deposition] [First Patterning] [Second Patterning] [Final Pattern]

## Decomposition for DPL

The first patterning
The second patterning


## Balanced Density

Unbalanced decomposition: 38\%(Red) and 62\% (Blue)
Dense region causes a disconnection


Balanced decomposition: 48\%(Red) an 52\% (Blue)


## Balanced density is preferred during layout decomposition

## More Decomposition Requirements

Minimum Stitch Insertion


1) Yield loss with overlay
2) Area increase due to overlap margin
[Lucas SPIE'08]

## Overlay Compensation


$1^{\text {st }}$ patternin

Without Overlay Compensation

| $2^{\text {nd }}$ patterning | 1 1st patterning |
| :---: | :---: |
| $=C_{1}-\Delta C_{1}$ | $\mathrm{C}_{2}+\Delta \mathrm{C}_{2} \uparrow$ |
| $1{ }^{\text {st }}$ patterninc | $2^{\text {nd }}$ patterning |

With Overlay Compensation

## Comparisons \& Complexity

## Previous Approach

| Balanced <br> Density | Overlay <br> Compensation | Stitch <br> Minimization | Complexity |
| :---: | :---: | :---: | :---: |
| No | No | Yes <br> (ILP) | NP-Complete |
| Yes | Yes | Yes <br> (Bi-Partitioning) | Polynomial <br> Time <br> O(NlogN) |

## Complexity of Our Decomposition Algorithm

N \# of rectangles, and E \# of neighboring pairs.

1) Segmentation from polygon to rectangles
$\rightarrow \mathrm{O}(\mathrm{N})$
2) Finding neighbors (sorting according to coordinate)
$\rightarrow \mathrm{O}(\mathrm{NlogN})$
3) The complexity of projection to non-touching neighbor
$\rightarrow \mathrm{O}(\mathrm{E})$
4) Grouping and relative coloring using DFS
$\rightarrow \mathrm{O}(\mathrm{N}+\mathrm{E})$
5) Group color assignment with min-cut partitioning
$\rightarrow \mathrm{O}(\mathrm{N})$
Overall complexity
$\Rightarrow \mathrm{O}(\mathrm{N} \log \mathrm{N})$

## Overall decomposition flow



Pre-Processing

## N: \# of rectangles,

 E: \# of neighboring pairs

Overall complexity is $\mathrm{O}(\mathrm{Nlog} \mathrm{N})$


## Group color assignment

 : Balance, min-stitch (Section 3.3-5 )

## Complexity: O(NlogN)




## Grouping and Relative Coloring



Grouping and Relative Coloring is done by DFS(Complexity: O(N+E))

r1 and r 4 should have different color r3 and r5 should have different color r2 can have any color

Relative coloring is a procedure assigning a color to remove conflicts

 constraints constraints for critical nets
(Section 4.1 )

No conflict, 23 stitches


No conflict, 2 stitches

## Color Assignment - Exact Solution

Example of Stitch Minimization


## ILP formulation for Stitch Minimization (Exact Solution)

Minimize: $\sum X_{w}$
Subject To:

$$
\begin{aligned}
& : A_{w}-B_{w} \leq X_{w} \\
& : B_{w}-A_{w} \leq X_{w}
\end{aligned}
$$

N groups in layout
$\rightarrow 2^{\mathrm{N}}$ solution
$\rightarrow$ NP-Complete
$\rightarrow$ Need a heuristic method

## Color Assignment - Heuristic Solution

## Theorem 1 : Min-Cut Based Stitch Minimization

The number of stitches in layout decomposition is equal to the cut size of the bi-partitioning problem in graph theory.

## Example of Graph Based Stitch Minimization



Minimize :
$A \oplus X+X \oplus Z+Y \oplus Z+E \oplus Y+2(\bar{A} \oplus X)+2(\overline{\mathrm{E}} \oplus \mathrm{Y})$


Constraint:
( $\mathrm{A}, \overline{\mathrm{A}}$ ) and ( $\mathrm{E}, \overline{\mathrm{E}}$ ) are repulsive pairs.

## Graph Partitioning Based Decomposition

## Min-Stitch Coloring



## Balanced Coloring



## Modification of FM partitioning

## Repulsive Pair Consideration



Local Density Consideration

| $R_{11}$ | $R_{12}$ | $R_{13}$ | $\ldots$ | $R_{1 i}$ |
| :---: | :---: | :---: | :---: | :---: |
| $R_{21}$ | $R_{22}$ | $R_{23}$ | $\ldots$ | $R_{2 i}$ |
| $R_{31}$ | $R_{32}$ | $R_{33}$ | $\ldots$ | $R_{3 i}$ |
| $\ldots$ | $\ldots$ | $\ldots$ | $\ldots$ | $\ldots$ |
| $R_{j 1}$ | $R_{j 2}$ | $R_{j 3}$ | $\ldots$ | $R_{j i}$ |

$$
\begin{gathered}
r W_{11}-\operatorname{smax}_{11} \leq\left|A_{11}\right| \leq r W_{11}+\operatorname{smax}_{11} \\
\mathrm{rW}_{12}-\operatorname{smax}_{12} \leq\left|A_{12}\right| \leq \mathrm{rW}_{12}+\operatorname{smax}_{12} \\
\vdots \\
r W_{j i}-\operatorname{smax}_{\mathrm{ji}} \leq\left|A_{\mathrm{ji}}\right| \leq \mathrm{rW}_{\mathrm{ji}}+\operatorname{smax}_{\mathrm{ji}}
\end{gathered}
$$

We implemented FM partitioning with the two new features

## Minimize $\Delta$ Delay due to Overlay

## $1^{\text {st }}$ Order Expression of $\Delta$ Delay

$$
\sqrt{\alpha^{2}+\beta^{2}} \sin (\theta+\phi)
$$

where, $\quad \alpha=2 A X^{T}-\sum_{n=1}^{i} a_{n}, \quad \beta=2 B Y^{T}-\sum_{n=1}^{j} b_{n}$

$$
\begin{aligned}
& X=\left[x_{1}, x_{2}, \ldots, x_{i}\right], \quad Y=\left[y_{1}, y_{2}, \ldots, y_{j}\right] \\
& \phi=\sin ^{-1}\left(\frac{\beta}{\sqrt{\alpha^{2}+\beta^{2}}}\right)
\end{aligned}
$$

## Theoram2

Horizontal direction and Vertical direction can be optimized independently to minimize $\Delta$ Delay due to Overlay


## Timing Driven Decomposition(TDD)

$$
\begin{aligned}
\text { minimize } & 4 \sum_{n=1}^{i}\left\{a_{n}\left(A W_{n}^{T}-w_{n n} \sum_{p=1}^{i} a_{p}\right)\right\}+\left(\sum_{p=1}^{i} a_{p}\right)^{2} \\
\text { s.t. } & w_{i i}=x_{i} \\
& 1+w_{i j} \geq x_{i}+x_{j} \\
& x_{i} \geq w_{i j} \\
& x_{j} \geq w_{i j}
\end{aligned}
$$

Two Possible Solutions


## Decomposition with TDD constraint


$X_{0}=\left\{x_{1}, x_{2}{ }^{\prime}\right\}, Y_{0}=\left\{y_{1}, y_{2}{ }^{\prime}\right\}$ to minimize $\alpha^{2}, \beta^{2}$
TDD Constraints insertion


Group color assignment when the edge weight(w) is bigger than one: Two stitches

## Runtime Result



Complexity: $\mathbf{O}(\mathbf{N l o g N}) \rightarrow$ Don't need layout partitioning

## Balanced Density Result



S38584:13\% and 87\%


|  |
| :---: |
|  |  |
|  |  |
|  |  |
|  |  |
|  |  |
|  |  |
|  |  |
|  |  |



## Exact vs. Heuristic comparison

|  |  |  | No balance, ILP (Exact) |  |  |  | No balance, Graph Partition (Proposed heuristic) |  |  |  | 48\% balance, Graph Partition (Proposed heuristic) |  |  |  |
| :---: | :---: | :---: | :---: | :---: | :---: | :---: | :---: | :---: | :---: | :---: | :---: | :---: | :---: | :---: |
| Circuit | \#Groups | neighbors | $\#$ <br> Partitions <br> for ILP | RunTime (total) | Inserted stitches | Balanced ratio(\%) | RunTime comparison | RunTime (total) | Inserted stitches | Balanced ratio(\%) | RunTime comparison | RunTime (total) | Inserted stitches | Balanced ratio(\%) |
| C432 | 1512 | 1098 | 1 | 0.63 | 1 | 20.35 | x1.4 | 0.46 | 1 | 33.60 | x1.0 | 0.65 | 2 | 48.12 |
| C499 | 3103 | 3280 | 12 | 100.85 | 50 | 24.01 | x49.9 | 2.02 | 50 | 46.47 | x49.9 | 2.02 | 50 | 48.50 |
| C880 | 3758 | 2631 | 14 | 4525.57 | 198 | 30.09 | x2773.0 | 1.63 | 198 | 47.12 | x2807.4 | 1.61 | 198 | 48.87 |
| C1355 | 4836 | 3083 | 18 | 702.4 | 114 | 18.91 | x347.4 | 2.02 | 114 | 36.12 | x344.0 | 2.04 | 114 | 48.00 |
| C1908 | 7795 | 5472 | 18 | 37019.7 | 371 | 22.09 | x9762.6 | 3.79 | 372 | 46.78 | x10422 | 3.55 | 373 | 48.66 |
| C2670 | 12863 | 9905 |  | $>24 \mathrm{Hr}$ |  |  |  | 6.7 | 947 | 43.51 |  | 6.87 | 948 | 49.30 |
| C3540 | 16638 | 12021 |  | $>24 \mathrm{Hr}$ |  |  |  | 9.85 | 1034 | 41.46 |  | 10.07 | 1034 | 49.39 |
| C5315 | 24483 | 18373 |  | $>24 \mathrm{Hr}$ |  |  |  | 17.43 | 1546 | 40.87 |  | 18.5 | 1549 | 48.00 |
| C6288 | 19922 | 11577 |  | $>24 \mathrm{Hr}$ |  |  |  | 11.57 | 256 | 30.81 |  | 11.25 | 256 | 48.13 |
| C7552 | 34309 | 24789 |  | $>24 \mathrm{Hr}$ |  |  |  | 30.89 | 2058 | 41.97 | - | 31.52 | 2060 | 48.02 |

## Runtime : Bi-partitioning based decomposition is up to 10 K faster than ILP based decomposition.

Accuracy: C1908 has two more stitches in our heuristic algorithm. All benchmarks except C1908 have the same \#stitches.

## Overlay compensation result



We could compensate overlay effect on timing More stitches $\rightarrow$ Less overlay effect on timing

## Conclusion \& Future Works

- Graph-based multi-objective decomposition
, Super linear time complexity : O(NlogN)
, Stitch minimization
, Balanced density
, Constraint insertion : overlay compensation
- Future work
, Multiple Decomposition for Multiple Patterning
, Correlation Aware Decomposition

